

## Supporting Information

### **AlF<sub>3</sub>-modified carbon nanofibers as multifunctional 3D interlayer for stable lithium metal anode**

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## **Experimental Section**

### **Preparation of the AlF<sub>3</sub>@CNF interlayer**

AlF<sub>3</sub>@CNFs were prepared by electrospinning and subsequent carbonization. AlF<sub>3</sub> (99.9%, Aladdin) powders were firstly treated by ball milling to get smaller crystal size. Afterwards, AlF<sub>3</sub> powders (20% in weight in PAN) with diameter of submicron were dispersed via ultrasonic in dimethylformamide (DMF, 99.9%, Aladdin). After uniformly dispersing the AlF<sub>3</sub> powder, Polyacrylonitrile (PAN, Aldrich, MW=150,000) was dissolved in as-prepared dispersion (10% in weight in DMF) at 70 °C and was used as the precursor for electrospinning. During the fiber fabrication, the flow rate maintained at 1 mL h<sup>-1</sup>, and a high voltage of 16 kV was applied between the tip and collector (distance: 15 cm). Finally, a white thin film was collected from the aluminum foil on a drum and was calcinated at 700 °C for 1 h under argon flow. The thickness of the whole AlF<sub>3</sub>@CNF interlayer can be easily controlled by the electrospinning process. In this study, the interlayer is thin (ca. 100 μm) and ultralight (ca. 1.8 mg cm<sup>-2</sup>).

### **Preparation of the CNF interlayer**

The preparation process of the carbon nanofiber (CNF) was similar to the method used for the AlF<sub>3</sub>@CNF interlayer. The difference is that the CNF interlayer was obtained without AlF<sub>3</sub> powders added. The CNF interlayer was placed on the top of Cu foil to form a new modified electrode (denoted as Cu-CNF).

### **Preparation of the Cu-AlF<sub>3</sub>/PAN400 electrode**

The protective layers were obtained using AlF<sub>3</sub> powders mixed with pre-dissolved PAN solution (10% in weight in DMF), with a weight ratio of 8:2. The slurry was coated on the copper foils. After removing the solvent at 80°C under vacuum, the layers were heated in furnace under argon flow at 400°C for 2 hours.

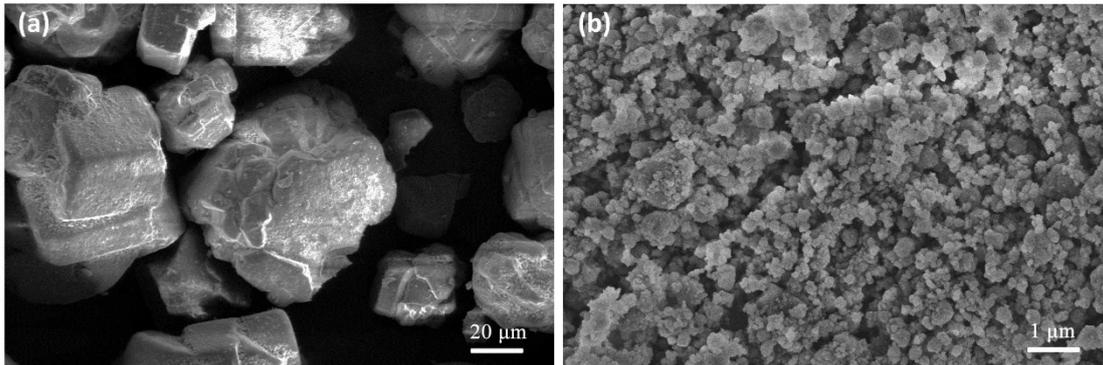
### **Electrochemical measurements**

The CR2016 coin-type cells were assembled in an Ar-filled glove box for all electrochemical tests. The Celgard 2400 membrane was used as the separator and the solution of 1M LiPF<sub>6</sub> in EC/DMC (v/v=1;1) with 10 wt% FEC was used as the electrolyte. For the Coulombic efficiency test, the cells were firstly cycled between 0.01-1.2V at 1 mA for 3 cycles to stabilize the SEI. Cyclic voltammogram measurement (CV) was performed using a CHI760E Electrochemical Workstation

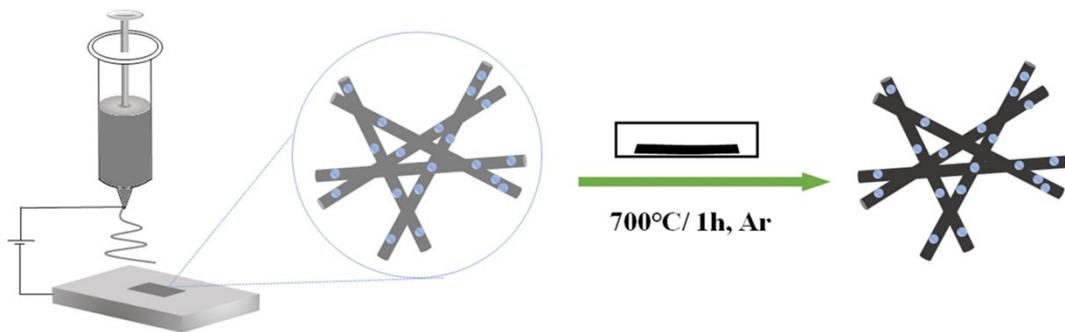
(Shanghai, China) between -0.1 V and 1 V at the scan rate of 0.1 mV/s. The electrochemical impedance spectroscopy (EIS) was measured on an Autolab Workstation (PGSTAT302N, Metrohm) with the frequency ranging from 100 kHz to 0.01 Hz. For full cells, the preparation of S@pPAN cathode materials has been reported in our previous work<sup>[1]</sup>. The cathode electrodes were prepared by casting a water slurry containing S@pPAN, Super P and carbonyl- $\beta$ -cyclodextrin binder in a weight ratio of 8:1:1 onto carbon-coated Al foil<sup>[2]</sup>. The cathodes were cut into discs with a diameter of 12 mm and dried at 60°C before use. The cathode loading was about 1.8 mg cm<sup>-2</sup>. All electrochemical tests were measured at 25°C.

### **Materials characterization**

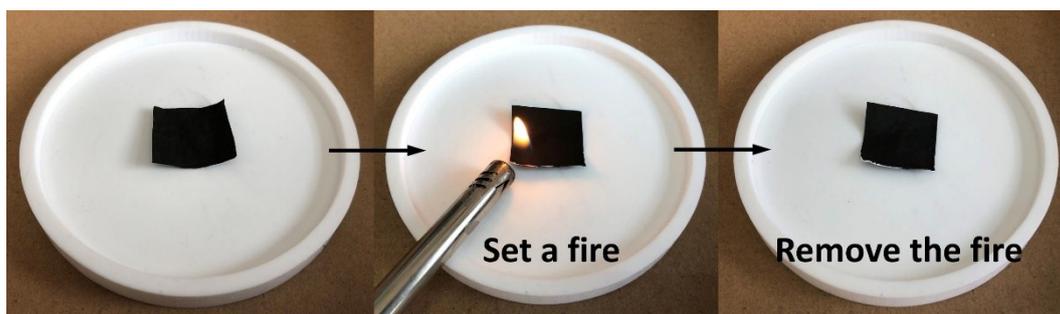
For the field emission scanning electron microscopy (SEM, Nova NanoSEM 230, FEI company, USA) analysis, the interlayers after different cycles were first taken out from disassembled cells in an Ar-filled glove box, and then gently rinsed with DMC to remove residual lithium salts and electrolyte. Afterwards, the interlayers were sealed in an Ar-filled container and transferred to the SEM chamber without exposed to air. Powder X-ray diffraction (XRD, D8 Advance, Bruker Corp., Germany) was conducted using Cu-K $\alpha$  radiation ( $\lambda=0.15418$  nm) at 40 kV. The thickness of the interlayer was all measured using a micrometer caliper (IP 65, Mitutoyo company, Japan). The resistivity of the whole interlayer was measured using a four-point-probe tester (SB100A-21), and the thickness of the interlayer is 100 $\mu$ m.



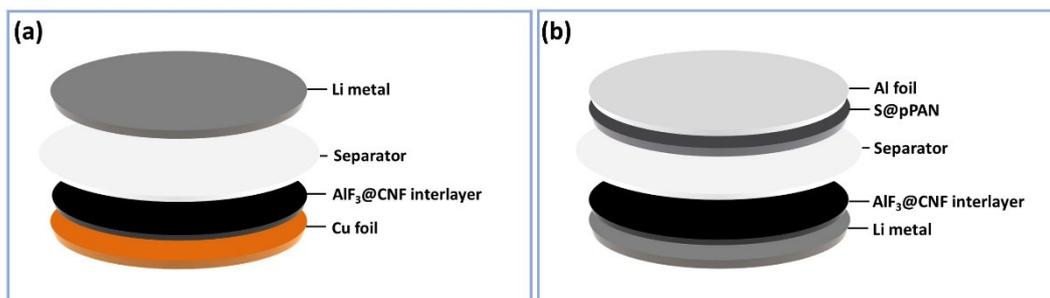
**Fig. S1** SEM images of AlF<sub>3</sub> powder (a) before and (b) after ball milling.



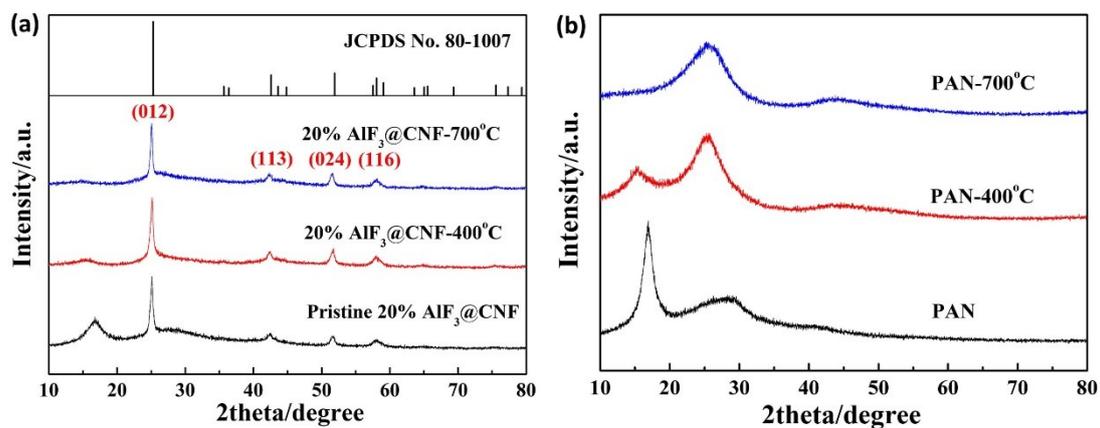
**Fig. S2** Schematic illustration of the synthesis procedure of the AlF<sub>3</sub>@CNFs.



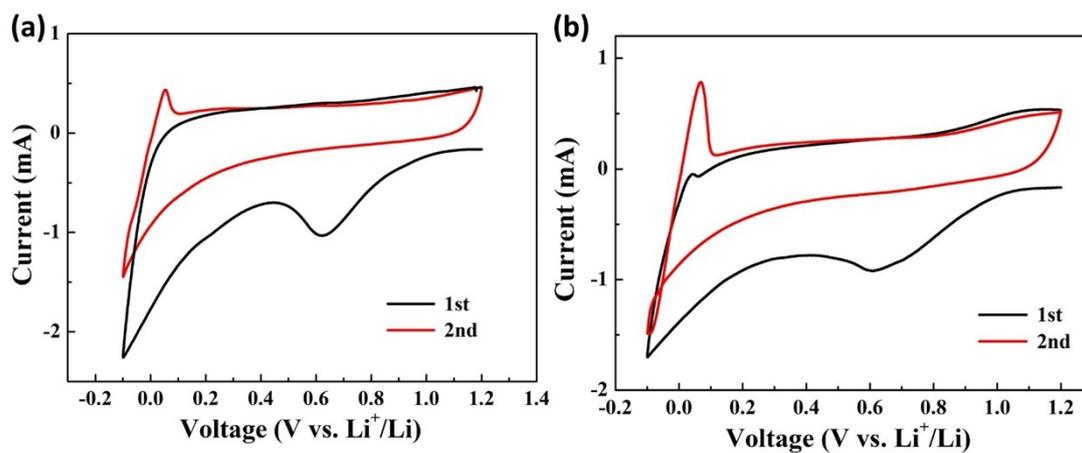
**Fig. S3** The nonflammability test of the  $\text{AlF}_3@\text{CNF}$ .



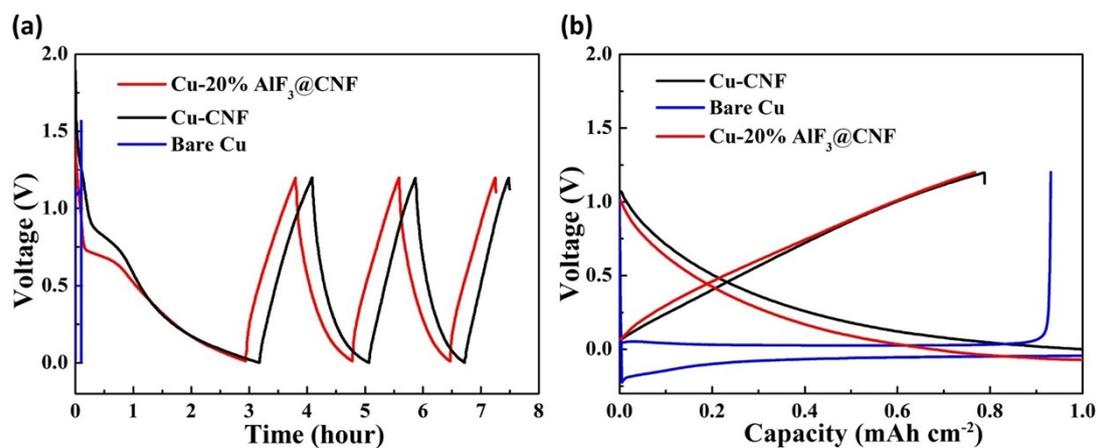
**Fig. S4** Schematic diagram of the configurations used for modified electrode with  $\text{AlF}_3@\text{CNF}$  interlayers: (a)  $\text{Cu}-\text{AlF}_3@\text{CNF}$  with Li metal as the counter electrode; (b)  $\text{Li}-\text{AlF}_3@\text{CNF}$  with  $\text{S@pPAN}$  as the cathode.



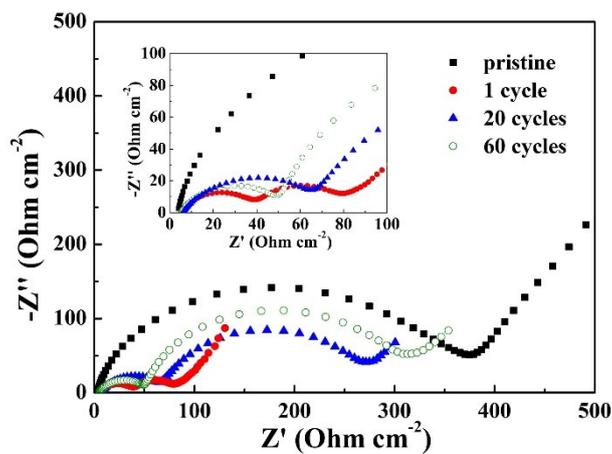
**Fig. S5** XRD spectra of (a) 20% AlF<sub>3</sub>@CNF electrode and (b) PAN powders treated at various temperature.



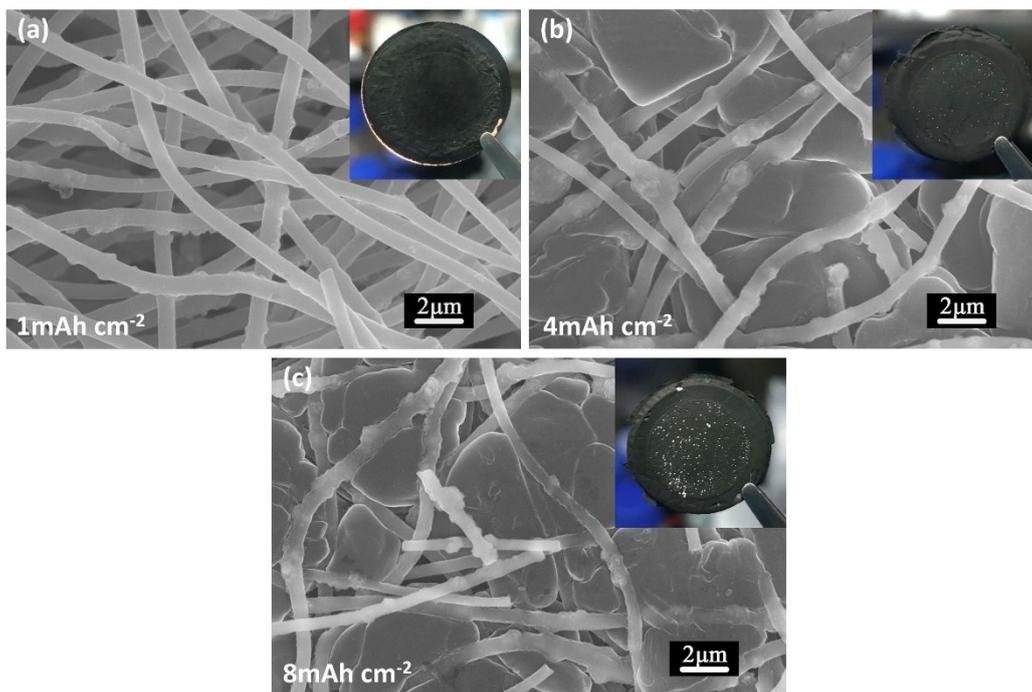
**Fig. S6** Cyclic voltammogram of (a) Cu-CNF and (b) Cu-20% AlF<sub>3</sub>@CNF electrode with Li counter electrode at a sweep rate of 0.1 mV s<sup>-1</sup>.



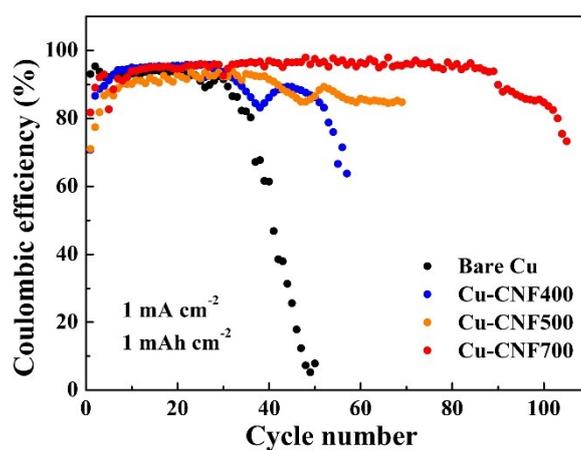
**Fig. S7** (a) Voltage profiles during initial activation process of various electrodes. (b) The voltage profiles of the first cycle (after activation) of Bare Cu, Cu-CNF and Cu-20%AlF<sub>3</sub>@CNF.



**Fig. S8** Nyquist plots of Cu-CNF electrode before and after cycling.



**Fig. S9** SEM images of Li deposition on Cu-20% AlF<sub>3</sub>@CNF electrode at the current density of 1 mA cm<sup>-2</sup> for different capacities: (a) 1 mAh cm<sup>-2</sup>, (b) 4 mAh cm<sup>-2</sup>, (c) 8 mAh cm<sup>-2</sup>. The inset is the corresponding digital photos.



**Fig. S10** The comparison of the CE of Li deposition on Cu-CNF electrodes treated at various temperature at 1 mA cm<sup>-2</sup> for 1 mAh cm<sup>-2</sup>.

**Table S1.** Mechanical properties of the PAN fibers treated at various temperatures<sup>[3]</sup>.

<b>Temperature (°C)</b>	120	300	400	500	600	700
<b>Young's Moduli (GPa)</b>	4	11	10	11	27	<b>47</b>

**Table S2.** Summary of the electrochemical plating/stripping performances in the reported literature.

Materials/electrode	Components of electrolytes	Capacity (mAh cm <sup>-2</sup> )	Current density (mA cm <sup>-2</sup> )	Cycle life (h)	Coulombic efficiency (%)
3D glass fiber @Cu <sup>[4]</sup>	1 M LiTFSI in DOL and DME with 2% LiNO <sub>3</sub>	0.5	1	67h	97
3D oxidized PAN Nanofiber @Cu <sup>[5]</sup>	1 M LiTFSI in DOL and DME with 2% LiNO <sub>3</sub>	1	1	240h	97.9%
PAN fiber array @Cu <sup>[6]</sup>	1 M LiTFSI in DOL and DME with 2% LiNO <sub>3</sub>	1	1	500h	97.4%
Interconnected hollow Carbon @Cu <sup>[7]</sup>	1 M LiTFSI in DOL and DME with 1% LiNO <sub>3</sub> and Li <sub>2</sub> S <sub>8</sub> additives.	1	1	300h	97.5%
3D Graphene@Ni Scaffold <sup>[8]</sup>	1 M LiTFSI in DOL and DME with 2% LiNO <sub>3</sub>	1	1	200h	92%
LiF with PAN binder @Cu <sup>[3]</sup>	1 M LiPF <sub>6</sub> in EC and DEC with 5% FEC	1	1	400h	95%
SiO <sub>2</sub> @PMMA coating layer@Cu <sup>[9]</sup>	1 M LiPF <sub>6</sub> in EC and DEC with additives	2	1	~200h	87% (After 100 cycles)
VGCF@GF <sup>[10]</sup>	1 M LiPF <sub>6</sub> in EC and DEC with 5% VC	2.5	0.5	965h	91.1% (After 100 cycles)
This work	1 M LiPF <sub>6</sub> in EC and DMC with 10% FEC	1	1	900h	97.2%
		8	1	740h	97.3%

## References

- [1] J. Wang, L. Yin, H. Jia, H. Yu, Y. He, J. Yang, C. W. Monroe, *ChemSusChem*, **2014**, *7*, 563.
- [2] J. Wang, Z. Yao, C. W. Monroe, J. Yang, Y. Nuli, *Adv. Funct. Mater.*, **2013**, *23*, 1194.
- [3] Z. Zhang, Z. Peng, J. Zheng, S. Wang, Z. Liu, Y. Bi, Y. Chen, G. Wu, H. Li, P. Cui, Z. Wen, D. Wang, *J. Mater. Chem. A*, **2017**, *5*, 9339.
- [4] X. B. Cheng, T. Z. Hou, R. Zhang, H. J. Peng, C. Z. Zhao, J. Q. Huang, Q. Zhang, *Adv. Mater.*, **2016**, *28*, 2888.
- [5] Z. Liang, G. Zheng, C. Liu, N. Liu, W. Li, K. Yan, H. Yao, P. C. Hsu, S. Chu, Y. Cui, *Nano Lett.*, **2015**, *15*, 2910.
- [6] J. Lang, J. Song, L. Qi, Y. Luo, X. Luo, H. Wu, *ACS Appl. Mater. Inter.*, **2017**, *9*, 10360.
- [7] G. Zheng, S. W. Lee, Z. Liang, H. W. Lee, K. Yan, H. Yao, H. Wang, W. Li, S. Chu, Y. Cui, *Nat. Nanotechnol.*, **2014**, *9*, 618.
- [8] K. Xie, W. Wei, K. Yuan, W. Lu, M. Guo, Z. Li, Q. Song, X. Liu, J. G. Wang, C. Shen, *ACS Appl. Mater. Inter.*, **2016**, *8*, 26091.
- [9] W. Liu, W. Li, D. Zhuo, G. Zheng, Z. Lu, K. Liu, Y. Cui, *ACS Cent. Sci.*, **2017**, *3*, 135.
- [10] Y. Yang, J. Xiong, J. Zeng, J. Huang, J. Zhao, *Chem. Commun.*, **2018**, *54*, 1178.